

<p align="center">NATIONAL PHASE UTILITY APPLICATION</p> <p align="center">Transmittal to the (DO/EO/US) Under 35 USC 371</p>	<p>Attorney Docket No.: SHIGA7.041APC First Named Inventor: Yasuo Masuda Int'l Application No.: PCT/JP2004/010434 Int'l Filing Date: July 15, 2004 Priority Date Claimed: July 16, 2003 Title: POSITIVE PHOTORESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN Express Mail Label No.: EV718232874US</p>
<p>Direct all correspondence to Customer No.: 20995 Date: January 12, 2006 Page 1 of 3</p>	

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The following enclosures are transmitted herewith to be filed in the patent application of:

Inventors:

1. Yasuo Masuda
2. Toshiki Okui

APPLICATION ELEMENTS:

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) A copy of the International Application as filed (35 U.S.C. § 371(c)(2)) has been communicated by the International Bureau.
 - (X) PCT/IB/308 enclosed.
- (X) An English translation of the International Application as filed is attached hereto.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.
- (X) An Oath or Declaration signed by the inventors (35 U.S.C. § 371(c)(4)).

OTHER APPLICATION PARTS:

- (X) Preliminary Amendment in 6 pages.
- (X) Recordation form cover sheet and Assignment in 3 total pages (cover sheet & assignment).
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
 - (X) Listing 13 references.
 - (X) Enclosing 9 references.
- (X) Cover page of PCT publication WO 2005/007718 A1.
- (X) International Search Report and Written Opinion.
- (X) Application Data Sheet in 2 pages.

10/564453

NATIONAL PHASE UTILITY APPLICATION Transmittal to the (DO/EO/US) Under 35 USC 371	Attorney Docket No.: SHIGA7.041APC First Named Inventor: Yasuo Masuda Int'l Application No.: PCT/JP2004/010434 Int'l Filing Date: 12 JAN 2006 Priority Date Claimed: July 16, 2003 Title: POSITIVE PHOTORESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN Express Mail Label No.: EV718232874US
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FILING FEES:

FEE CALCULATION				
FEE TYPE & DETERMINATION		LARGE FEE	CALCULATION	TOTAL
Basic Filing Fee under 1.492(a)		1631 (\$300)		\$300
Search Fee under 1.492(b) (enter one in TOTAL column)				
(1)	USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)	1640 (\$0)		\$400
(2)	USPTO was the ISA (noncompliant claims)	1641 (\$100)		
(3)	Foreign Search Report Enclosed	1642 (\$400)		
(4)	No Search Report Enclosed	1632 (\$500)		
Examination Fee under 1.492(c) (enter one in TOTAL column)				
(1)	USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)	1643 (\$0)		\$200
(2)	Non US IPEA or Noncompliant Claims	1633 (\$200)		
Excess Claims	4 - 20 = 0	1615 (\$50)	0 x 50 =	\$0
Excess Ind. Claims	2 - 3 = 0	1614 (\$200)	0 x 200 =	\$0
Multiple Dep. Claim		1616 (\$360)		\$0
Application Size Fee	0 - 100 = 0	1681 (\$250)	0 x 250 =	\$0
Late English Translation		1618 (\$130)		
Assignment		8021 (\$40)	1 x 40 =	\$40
			TOTAL FEE DUE	\$940
TOTAL FEE PAID (If Different Than Fee Due)				\$

(X) A check in the amount of \$940 to cover the Total Fee Due is enclosed.

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<p>NATIONAL PHASE UTILITY APPLICATION</p> <p>Transmittal to the (DO/EO/US) Under 35 USC 371</p>	<p>Attorney Docket No.: SAHGA7 041APC First Named Inventor: Yasuo Masuda Int'l Application No.: PCT/JP2004/010434 Int'l Filing Date: July 15, 2004 Priority Date Claimed: July 16, 2003 Title: POSITIVE PHOTORESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN Express Mail Label No.: EV718232874US</p>	<p>12 JAN 2006</p>
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The Commissioner is hereby authorized to charge any additional fees which may be required, now or in the future, or credit any overpayment to Account No. 11-1410.



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Attorney Docket No. : SHIGA7.041APC
Applicant(s) : Masuda et al.
For : POSITIVE PHOTORESIST COMPOSITION
AND METHOD OF FORMING RESIST
PATTERN
Attorney : Daniel E. Altman
"Express Mail" Label No. : EV718232874US
Date of Deposit : January 12, 2006

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I hereby certify that the accompanying

Transmittal letter; English translation of specification in 51 pages; Preliminary Amendment in 6 pages; Application Data Sheet in 2 pages; Cover sheet of PCT publication; signed Declaration and Power of Attorney in 2 pages; Recordation Form Cover Sheet and Assignment in 3 pages; PCT/IB/308; International Search Report and Written Opinion; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 9 references; Check for Filing Fee; Return Prepaid Postcard

are being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 on the date indicated above and are addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.



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